

L10: Entry 112 of 118

File: JPAB

Print

Jun 12, 2001

PUB-NO: JP02001158691A

DOCUMENT-IDENTIFIER: JP 2001158691 A

TITLE: SAPPHIRE SUBSTRATE

PUBN-DATE: June 12, 2001

INVENTOR - INFORMATION:

NAME

COUNTRY

YAGUCHI, YOICHI SUNAKAWA, KAZUHIKO FURUTAKI, TOSHIRO KUROIWA, TERUO SATO, TSUGIO

ASSIGNEE-INFORMATION:

NAME

COUNTRY

NAMIKI PRECISION JEWEL CO LTD

APPL-NO: JP11338716

APPL-DATE: November 29, 1999

INT-CL (IPC): C30 B 29/20; H01 L 33/00

ABSTRACT:

PROBLEM TO BE SOLVED: To provide a sapphire substrate capable of subjecting various kinds of semiconductors including a semiconductor of group III nitride such as <u>GaN</u>, etc., and a semiconductor of <u>gallium nitride</u>-based compound such as GaAlN, etc., to excellent epitaxial growth and improving a yield.

SOLUTION: This sapphire substrate is used in the epitaxial growth of the semiconductors. The sapphire substrate has a crystal growth face to be subjected to crystal growth <u>tilted</u> from the axis c of the substrate by a fixed <u>angle</u> in a given <u>direction</u>.

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Sep 14, 2000

PUB-NO: JP02000252589A

DOCUMENT-IDENTIFIER: JP 2000252589 A

TITLE: GALLIUM NITRIDE SEMICONDUCTOR LASER ELEMENT AND ITS

MANUFACTURE

PUBN-DATE: September 14, 2000

INVENTOR-INFORMATION:

NAME

COUNTRY

OKUMURA, TOSHIYUKI

ASSIGNEE-INFORMATION:

NAME

COUNTRY

SHARP CORP

APPL-NO: JP11052074

APPL-DATE: March 1, 1999

INT-CL (IPC): HO1 S 5/323; HO1 L 33/00

ABSTRACT:

PROBLEM TO BE SOLVED: To increase the yield rate of gallium nitride semiconductor laser elements of a low oscillation threshold current by making specific an angle formed by the end surface of a resonator and the direction of the current constricting stripes of an active layer, and the full width at half maximum of the intensity distribution of a laser beam in a direction parallel to the active layer respectively.

SOLUTION: A crack preventing layer 3 is a ternary mixed crystal of In0.1Ga0.9N or InGaN other than this. An n-type clad layer 4 and a p-type first clad layer 11 are AlGaN ternary mixed crystals having Al composition other than Al0.1Ga0.9N. When the Al composition is larger, the energy gap difference and the refractive index difference between an active layer and a clad layer become larger, and carriers and light are effectively confined to the active layer, and an oscillation threshold current is reduced and the temperature property is improved. If stripes of ridge construction are aligned and the angle of a tilt formed by the direction of ridge stripes of each resonator and the end surface of the resonator is made to be in the extent of 90

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File: JPAB

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Oct 9, 1998

PUB-NO: JP410268225A

DOCUMENT-IDENTIFIER: JP 10268225 A

TITLE: ADJUSTING METHOD OF OPTICAL DEFLECTION DEVICE AND ADJUSTING

DEVICE THEREFOR

PUBN-DATE: October 9, 1998

INVENTOR-INFORMATION:

NAME

COUNTRY

SHIBUYA, SATOSHI

GAN, MASAO

KAMIMURA, SHOJI

ASSIGNEE-INFORMATION:

NAME

COUNTRY

KONICA CORP

APPL-NO: JP09074842

APPL-DATE: March 27, 1997

INT-CL (IPC): G02 B 26/10; G02 B 7/198

ABSTRACT:

PROBLEM TO BE SOLVED: To provide an adjusting method and an adjusting device so as to improve the accuracy of a tilt angle of an optical deflection device using a polygon mirror.

SOLUTION: This device is composed of a light source 301 irradiating the mirror surface 101A of a polygon mirror 101 and a light receiving element 302 receiving a reflected light beam from the mirror surface 101A, has a tilt angle adjusting means 400 composed of a tilt angle measuring instrument 300 for measuring the tilt angle of the mirror surface 101A and a pushing-up member 401A (B) acting in parallel with the axial direction of the polygon mirror 101 and, by measuring the tilt angle of the mirror surface 101 A and finely adjusting the tilt angle adjusting means 400 so as to decrease the variance of tilt angle of the mirror surface 101A, positional adjustment of the polygon mirror fitted over the outside cylinder 102 of the radial shaft is performed.

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L10: Entry 115 of 118

File: JPAB

Jul 31, 1997

PUB-NO: JP409199419A

DOCUMENT-IDENTIFIER: JP 09199419 A

TITLE: CRYSTAL GROWTH METHOD OF GALLIUM NITRIDE COMPOUND

SEMICONDUCTOR AND MANUFACTURE OF SEMICONDUCTOR LASER

PUBN-DATE: July 31, 1997

INVENTOR - INFORMATION:

NAME

COUNTRY

NIDOU, MASAAKI KIMURA, AKITAKA SUNAKAWA, HARUO

YAMAGUCHI, ATSUSHI ASSIGNEE-INFORMATION:

NAME

COUNTRY

NEC CORP

APPL-NO: JP08007340

APPL-DATE: January 19, 1996

INT-CL (IPC): H01 L 21/20; C30 B 29/38; H01 L 33/00; H01 S 3/18

ABSTRACT:

PROBLEM TO BE SOLVED: To improve the flatness and the orientational property of crystallization, and to decrease the defect of lamination by a method wherein the surface of a crystal substrate is formed in such a manner that the tilt angle of the plane direction, which is equivalent to specific plane direction, is set within a prescribed value.

SOLUTION: A GaN buffer layer 2 is crystal-grown on a sapphire substrate 1 having (1, -1, 0, 1) faces as the surface, and a GaN layer 3 is crystal-grown thereon. The crystal growth speed in the direction vertical to the (1,-1, 0, 1) faces is slow, and the atomic migration on the above-mentioned plane is intensified. As a result, a hexagonal gallium nitride compound semiconductor, which is smooth on the surface in the direction in parallel with the substrate surface and having uniform C-axial orientational direction, is formed. The same effect can be obtained even when the orientation of substrate is inclined by 5 degrees or less from the (1, -1, 0, 1) face orientation.

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L10: Entry 114 of 118

File: JPAB

Oct 9, 1998

PUB-NO: JP410268225A

DOCUMENT-IDENTIFIER: JP 10268225 A

TITLE: ADJUSTING METHOD OF OPTICAL DEFLECTION DEVICE AND ADJUSTING

DEVICE THEREFOR

PUBN-DATE: October 9, 1998

INVENTOR-INFORMATION:

NAME

COUNTRY

SHIBUYA, SATOSHI

GAN. MASAO

KAMIMURA, SHOJI

ASSIGNEE-INFORMATION:

NAME

COUNTRY

KONICA CORP

APPL-NO: JP09074842

APPL-DATE: March 27, 1997

INT-CL (IPC): GO2 B 26/10; GO2 B 7/198

ABSTRACT:

PROBLEM TO BE SOLVED: To provide an adjusting method and an adjusting device so as to improve the accuracy of a <u>tilt</u> angle of an optical deflection device using a polygon mirror.

SOLUTION: This device is composed of a light source 301 irradiating the mirror surface 101A of a polygon mirror 101 and a light receiving element 302 receiving a reflected light beam from the mirror surface 101A, has a tilt angle adjusting means 400 composed of a tilt angle measuring instrument 300 for measuring the tilt angle of the mirror surface 101A and a pushing-up member 401A (B) acting in parallel with the axial direction of the polygon mirror 101 and, by measuring the tilt angle of the mirror surface 101 A and finely adjusting the tilt angle adjusting means 400 so as to decrease the variance of tilt angle of the mirror surface 101A, positional adjustment of the polygon mirror fitted over the outside cylinder 102 of the radial shaft is performed.

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File: EPAB

Nov 20, 1996

PUB-NO: EP000743727A1

DOCUMENT-IDENTIFIER: EP 743727 A1

TITLE: GaN system semiconductor laser device

PUBN-DATE: November 20, 1996

INVENTOR-INFORMATION:

NAME COUNTRY

FUJII, HIROAKI JP

ASSIGNEE-INFORMATION:

NAME COUNTRY

NIPPON ELECTRIC CO JP

APPL-NO: EP96108019 APPL-DATE: May 20, 1996

PRIORITY-DATA: JP12187895A (May 19, 1995)

INT-CL (IPC): H01 S 3/19; H01 L 21/205; H01 L 21/20; H01 L 33/00;

C30 B 29/38

EUR-CL (EPC): H01L033/00; H01L033/00, H01S003/19

ABSTRACT:

A GaN system compound semiconductor double heterostructure in a light emission device comprises an active layer (1) sandwiched between first and second cladding layer (2,3). Those three layers are made of GaN system compound semiconductor materials. The first, second and third GaN system compound semiconductor materials have first, second and third hexagonal crystal structures of basal planes tilted from a (0001) plane by an angle in the range of 0 degree to a few degrees, and the basal planes are substantially parallel to interfaces of the active layer (1) to the first and second cladding layer (2,3). The GaN system compound semiconductor double heterostructure have a pair of opposite resonance faces vertical to a direction in which a light is emitted, and for each of the first, second and third hexagonal crystal structures, a pair of opposite planes in the six planes vertical to the basal plane forms the opposite resonance faces.

The double hetrostructure is formed on a <u>GaN</u> epitaxial layer (6) by selective area growth.



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End of Result Set

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File: DWPI

Apr 21, 1998

DERWENT-ACC-NO: 1996-508010

DERWENT-WEEK: 199823

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TITLE: Light emission laser device based on <u>gallium nitride</u> cpd. semiconductor - is double heterostructure device in which <u>gallium nitride</u> active layer and two outer cladding layers have hexagonal crystal structures of specific orientation

INVENTOR: FUJII, H

PATENT-ASSIGNEE: NEC CORP (NIDE)

PRIORITY-DATA: 1995JP-0121878 (May 19, 1995)

PATENT-FAMILY:

PUB-NO	PUB-DATE	LANGUAGE	PAGES	MAIN-IPC
US 5742628 A	April 21, 1998		012	H01S003/19
EP 743727 A1	November 20, 1996	E	016	H01S003/19
JP 08316582 A	November 29, 1996		005	H01S003/18

DESIGNATED-STATES: DE GB

CITED-DOCUMENTS:4.Jnl.Ref; EP 460710 ; EP 599224 ; EP 609799 ; JP 7122520 ; US 5247533

APPLICATION-DATA:

PUB-NO	APPL-DATE	APPL-NO	DESCRIPTOR
US 5742628A	May 20, 1996	1996US-0650439	
EP 743727A1	May 20, 1996	1996EP-0108019	
JP08316582A	May 19, 1995	1995JP-0121878	

INT-CL (IPC): C30 B 29/38; H01 L 21/20; H01 L 21/205; H01 L 33/00; H01 S 3/085; H01 S 3/18; H01 S 3/19

ABSTRACTED-PUB-NO: EP 743727A

BASIC-ABSTRACT:

Light emission device is a GaN system cpd semiconductor double heterostruc ture having an active layer (1) sandwiched between cladding layers (2,3). The three layers are made of respectively three GaN system materials having first, second and third hexagonal crystal structures of basal planes tilted from a (0001) plane by an



angle of zero to a few deg and the basal planes are parallel to the interfaces between the active and cladding layers. Pref the device forms a resonator and has a pair of opposite resonance faces vertical to the <u>direction</u> of light emission; and for each of the three hexagonal crystal structures, a pair of opposite planes in the six planes vertical to the basal plane forms the opposite resonance faces.

USE - As a blue-to-UV laser emitter useful as a light source for high density optical disc devices.

ADVANTAGE $\underline{\hspace{0.1cm}}$ GaN system double heterostructure laser emitter acting as a resonator is provided which is free of the resonator problems of prior art GaN system devices.

ABSTRACTED-PUB-NO: US 5742628A EQUIVALENT-ABSTRACTS:

Light emission device is a GaN system cpd semiconductor double heterostruc ture having an active layer (1) sandwiched between cladding layers (2,3). The three layers are made of respectively three GaN system materials having first, second and third hexagonal crystal structures of basal planes tilted from a (0001) plane by an angle of zero to a few deg and the basal planes are parallel to the interfaces between the active and cladding layers. Pref the device forms a resonator and has a pair of opposite resonance faces vertical to the direction of light emission; and for each of the three hexagonal crystal structures, a pair of opposite planes in the six planes vertical to the basal plane forms the opposite resonance faces.

USE - As a blue-to-UV laser emitter useful as a light source for high density optical disc devices.

ADVANTAGE $\underline{\ }$ GaN system double heterostructure laser emitter acting as a resonator is provided which is free of the resonator problems of prior art GaN system devices.

CHOSEN-DRAWING: Dwg.3/3 Dwg.3/3

DERWENT-CLASS: L03 U12 V08 CPI-CODES: L04-A02; L04-E03B;

EPI-CODES: U12-A01A1A; U12-A01B1A; V08-A01A; V08-A04A;



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<u>L11</u>	5742628	5	<u> </u>
<u>L10</u>	18 and 19	118	<u>L10</u>
<u>L9</u>	tilt\$4	275478	<u>L9</u>
<u>L8</u>	13 and 16	662	<u>L8</u>
<u>L7</u>	13 and 16L6	2	<u></u> <u>L7</u>
<u>L6</u>	14 or 15	9975	<u></u> <u>L6</u>
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<u>L4</u>	gallium adj nitride	3413	<u></u> <u>L4</u>
<u>L3</u>	11 same I2	590402	<u>L3</u>
<u>L2</u>	orientation or direction	3583448	<u></u> <u>L2</u>
<u>L1</u>	ang\$4	1986093	<u>L1</u>

END OF SEARCH HISTORY